

Patterning the adhesive properties of amine rich polymer films

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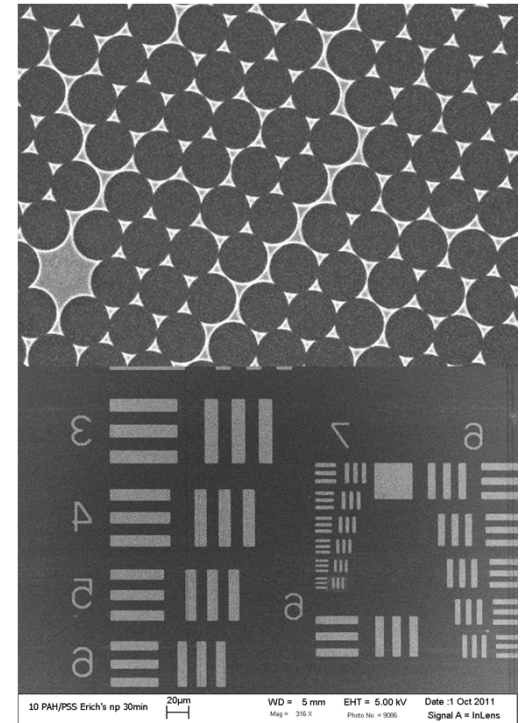
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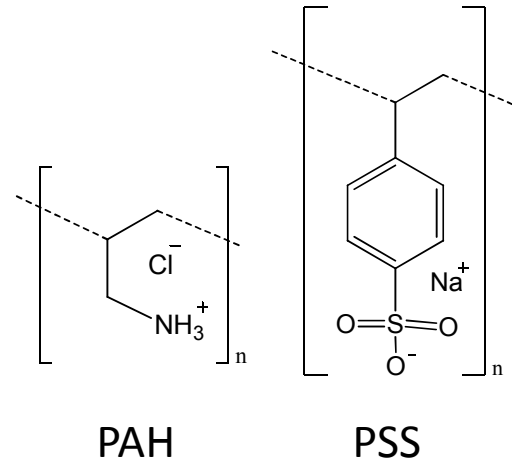
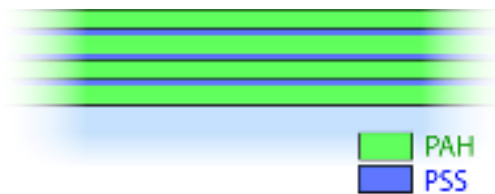
Patterned Surface Adhesion

- Selective deposition of nanoparticles and structures
- Patterned adhesion is useful for plasmonic devices, nanoscale devices, biomedical and tissue engineering
- Patterning entities not compatible with lithographic processes



Amine-rich ISAM film

(PAH/PSS)_n/PAH film deposited at high pH (9-9.5) contains large amounts of amine groups



Pioneered by M.F. Rubner:

J. Hiller et al., Nat. Mat. **2002**, 1, 59

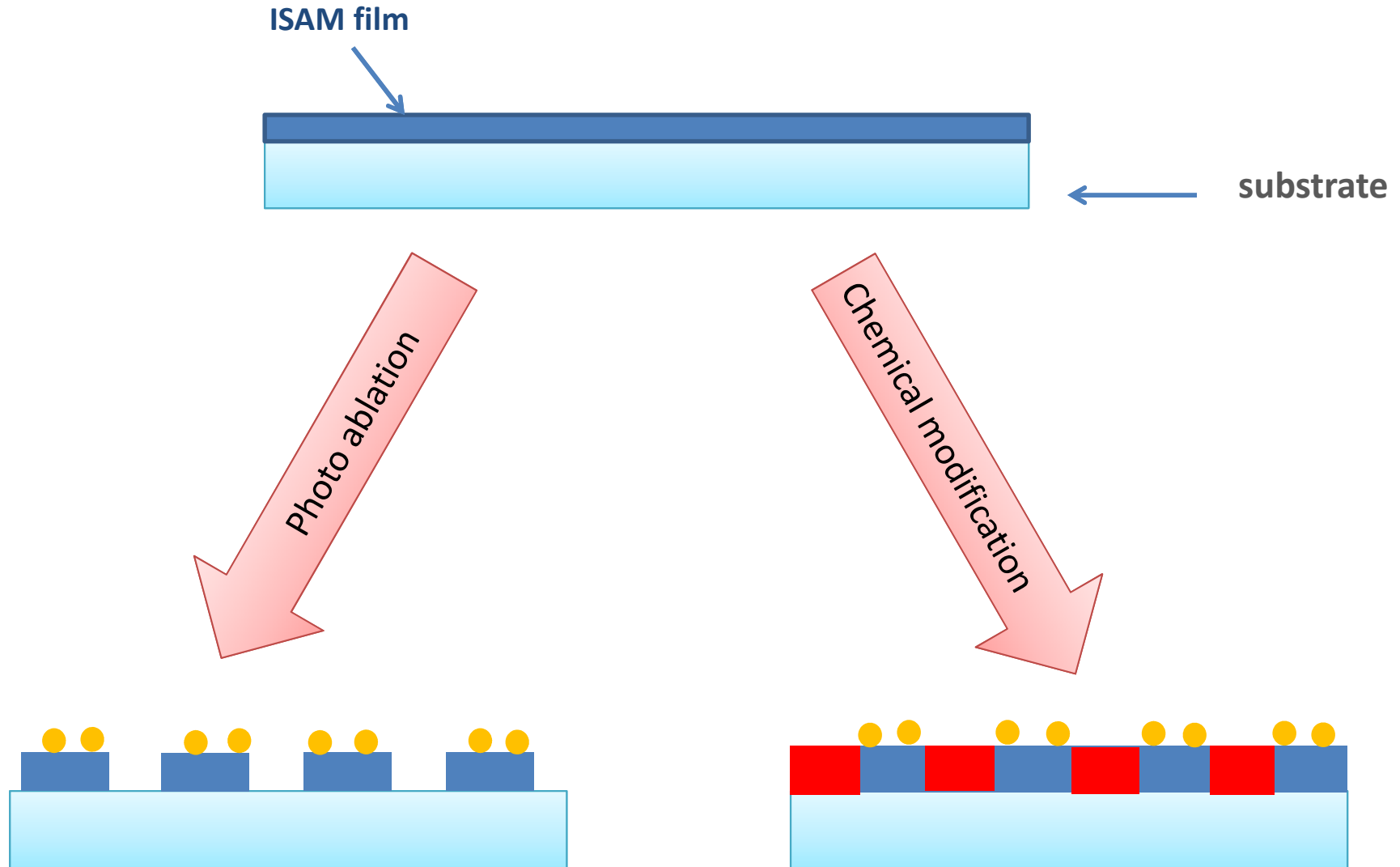
J. Hiller & M. F. Rubner, Macromol. **2003**, 36, 4078

K.-K. Chia et al., Chem. Mater **2008**, 20, 6756

The film undergoes hysteretic swelling and deswelling with pH

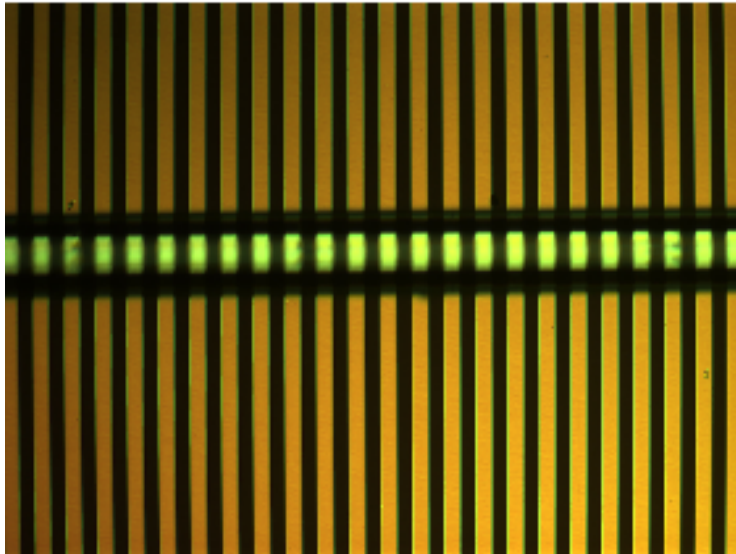
Creates opportunity to protect and rejuvenate the surface

Surface modification

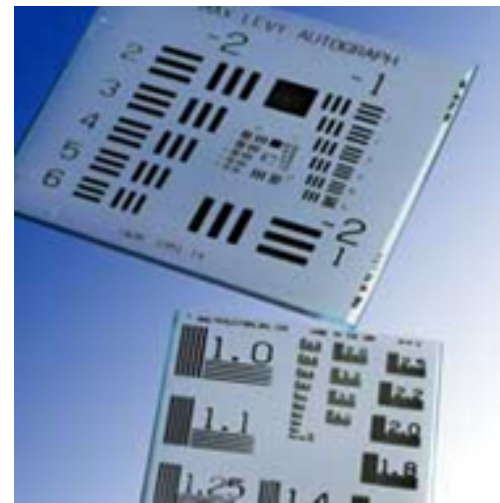
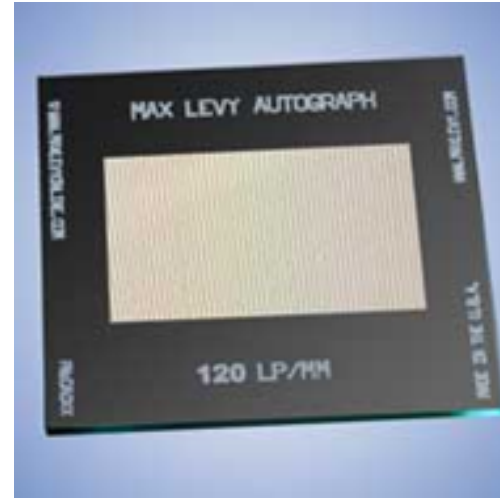


Photomasks (withstand high laser fluence)

Highly reflective metal film on fused silica substrate
(high UV transmission)



Optical microscope image of a photomask with a fiber sitting on top



Laser ablation patterning

(1)

Film deposition



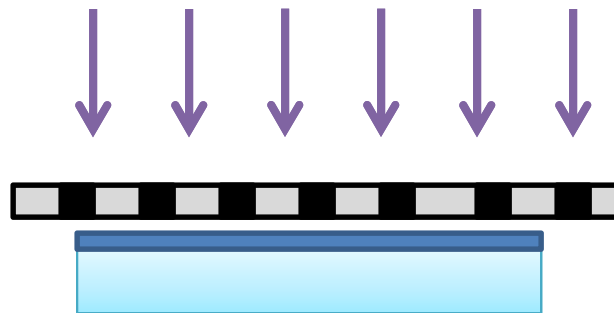
ISAM Film

Substrate

UV excimer laser 248 nm with pulse energy $\sim 45 \text{ mJ/cm}^2$

(2)

Laser ablation

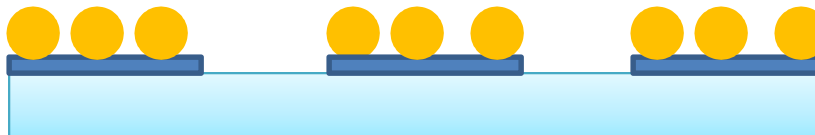


← Photomask

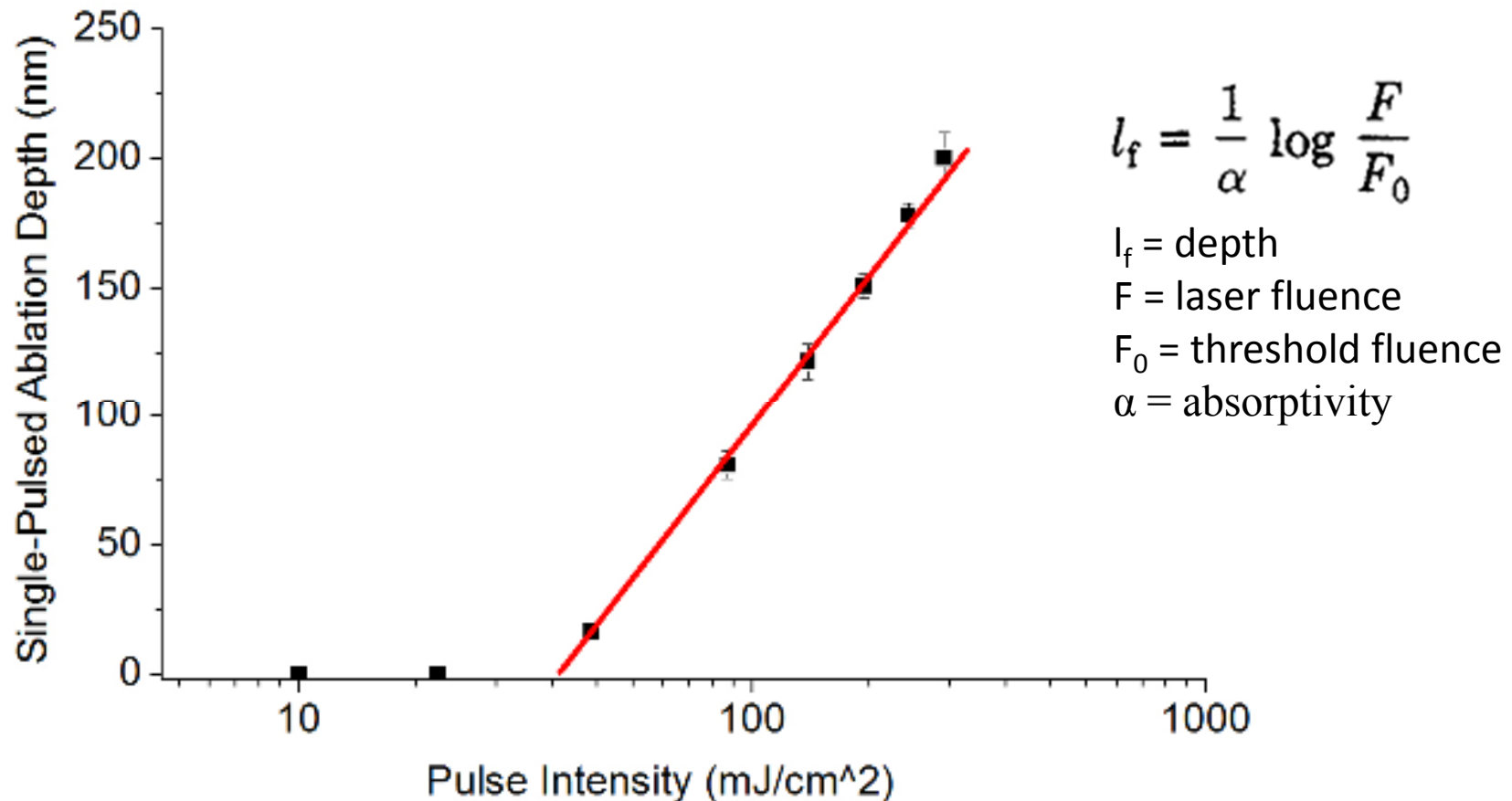
Nanoparticles selectively assemble on the patterned surface

(3)

Nanoparticle
Assembly



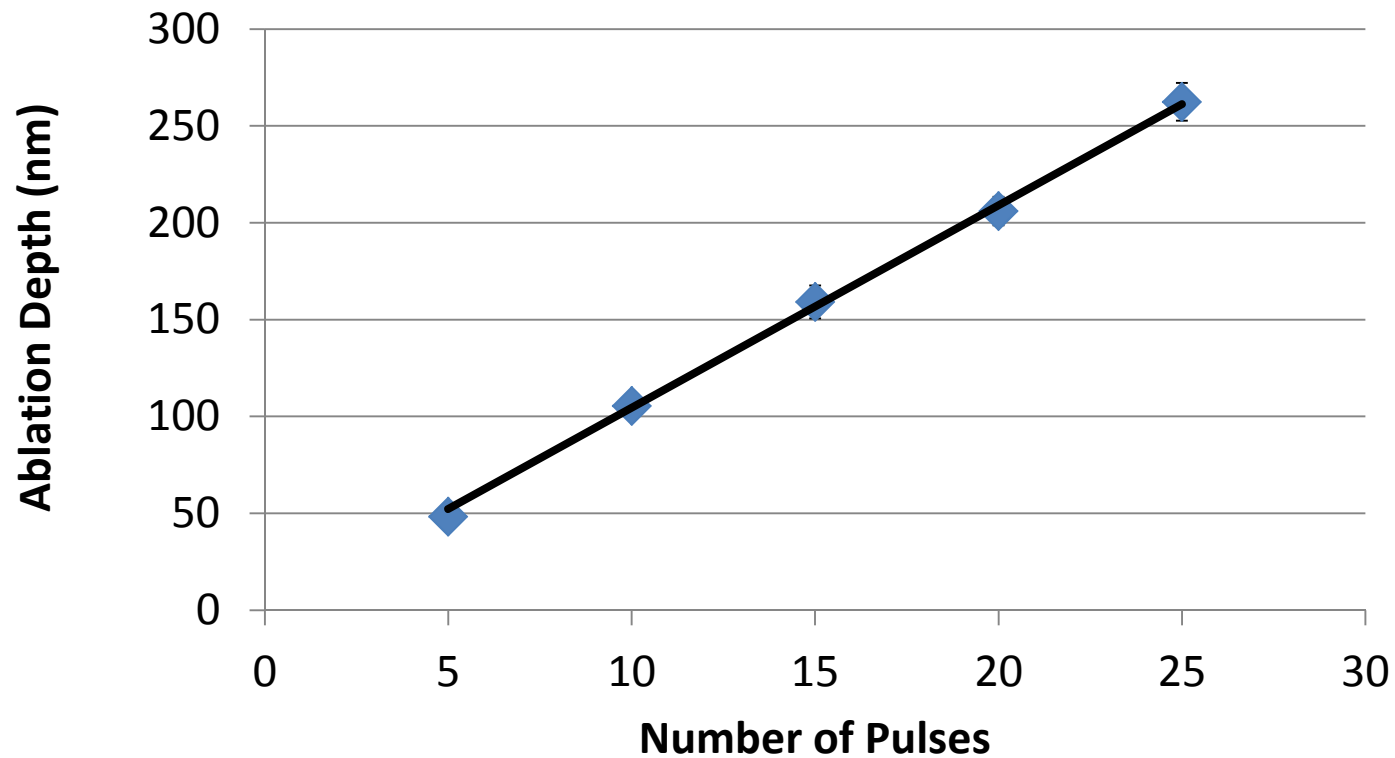
Laser ablation threshold for polymer films



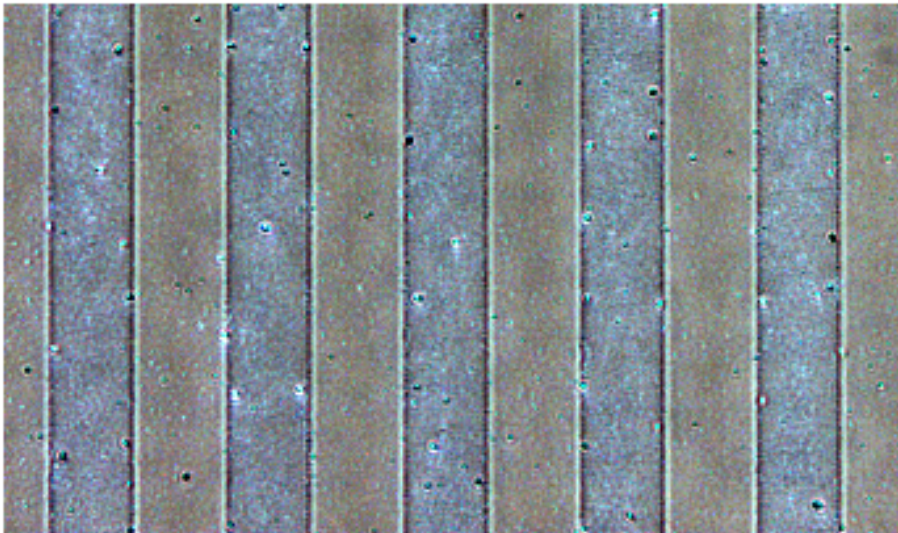
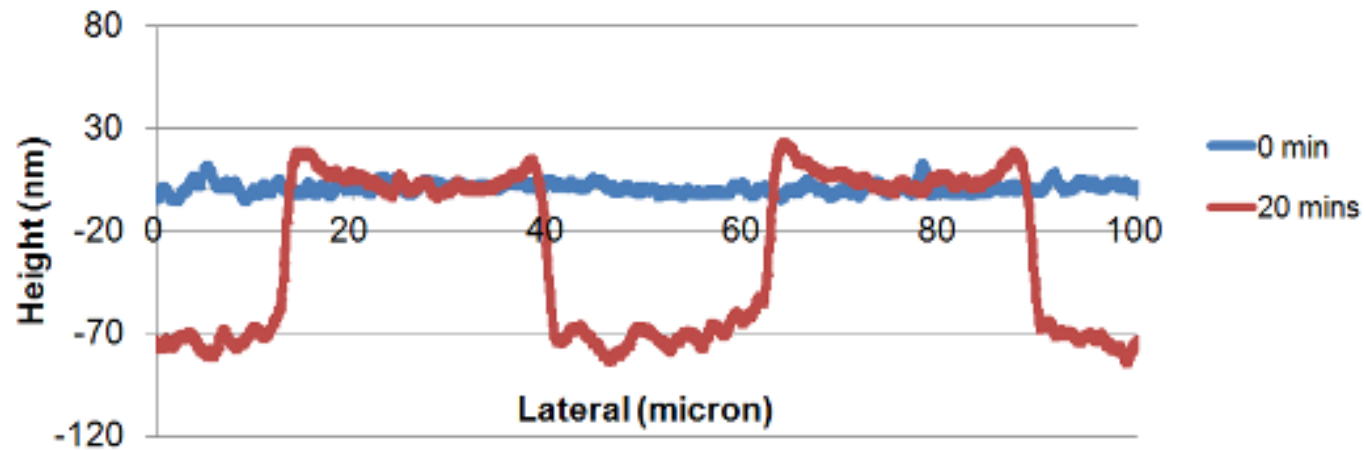
Threshold fluence of PAH/PB films $\sim 40 \text{ mJ/cm}^2$

Most ablation threshold of polymer films lies in $\sim 30\text{-}70 \text{ mJ/cm}^2$
glass 1.2 J/cm^2 .

Ablation depth vs number of laser pulses for polymer film (at 45 mJ/cm²)

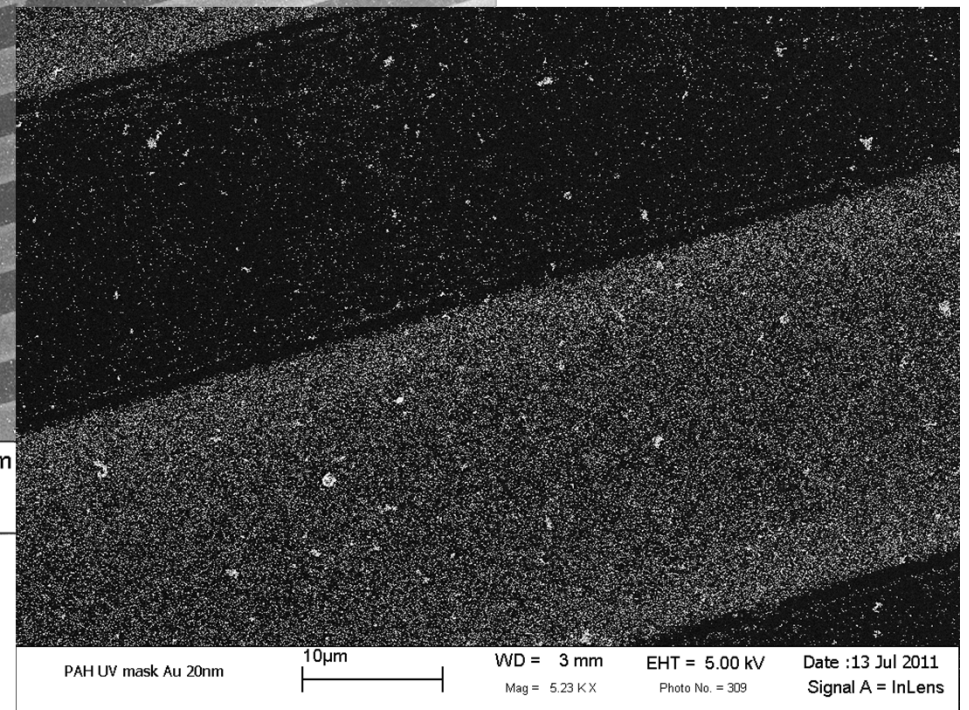
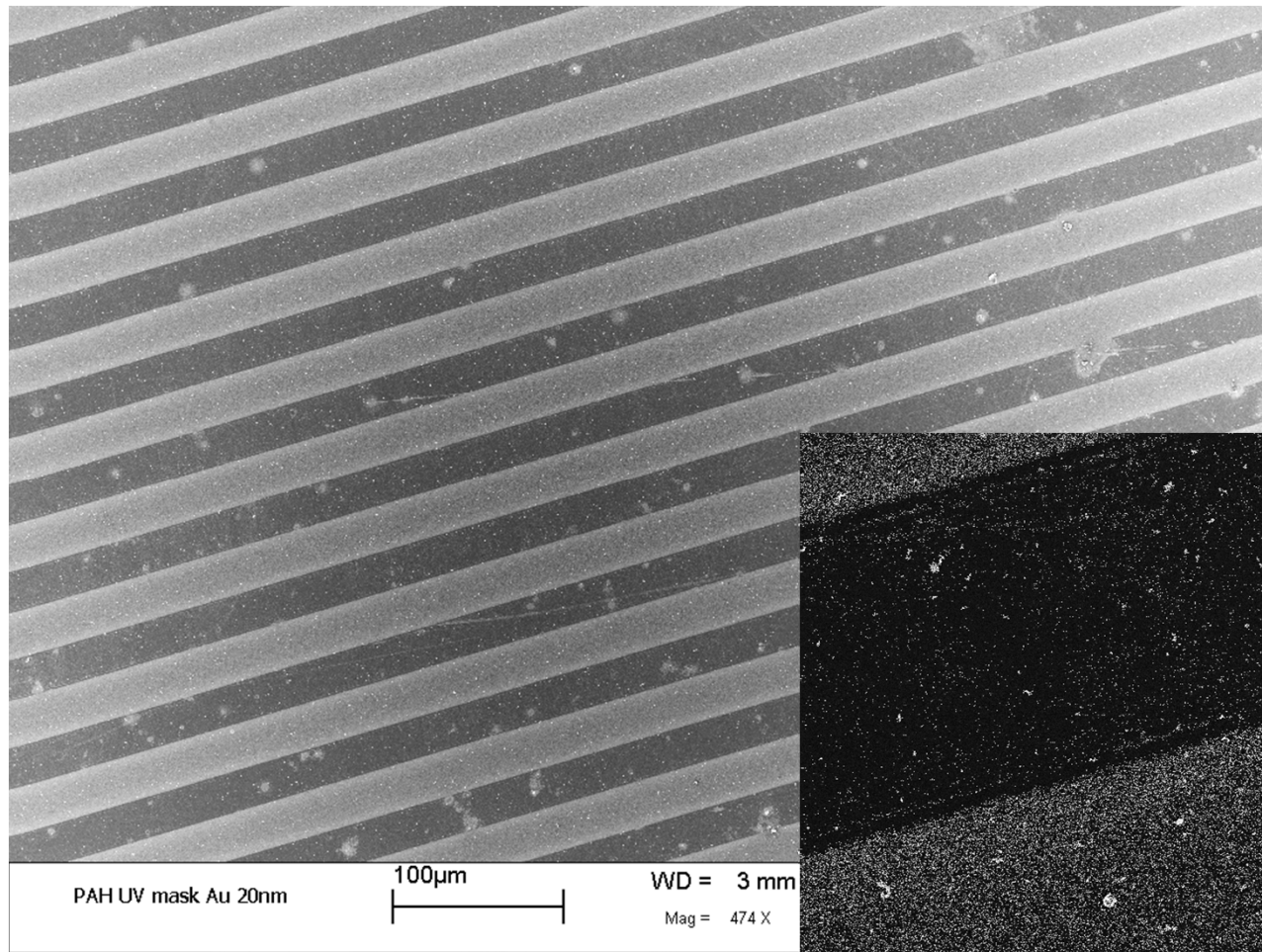


Laser Ablation profile of polymer films

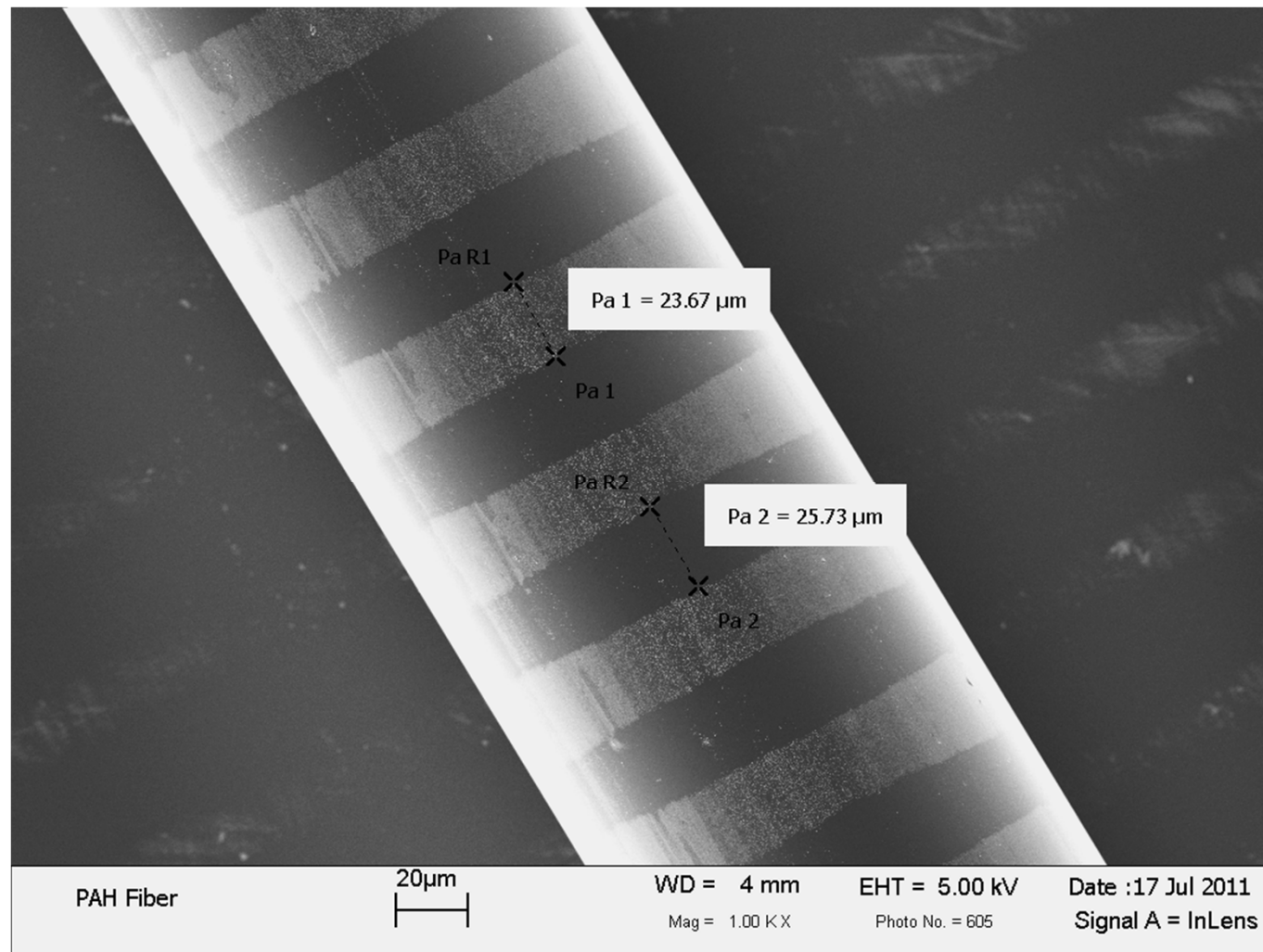


Phase-contrast optical microscope image of patterned (PAH/PSS)₁₀₀ film

Selective assembly of 20nm Au nanoparticles on 1PAH layer template



Nanoparticle pattern on one PAH layer coated fiber



Pattern of ISAM layer on planar substrate.

(1)

Film deposition

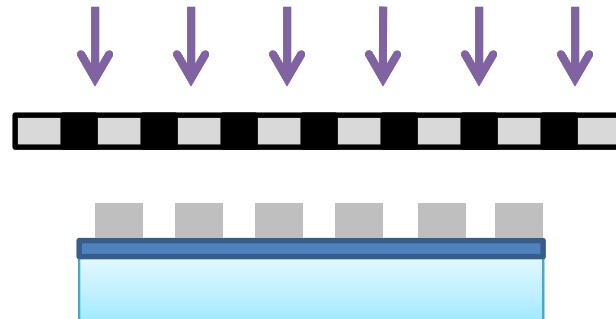


← ISAM Film
← Substrate

(2)

Metal evaporation

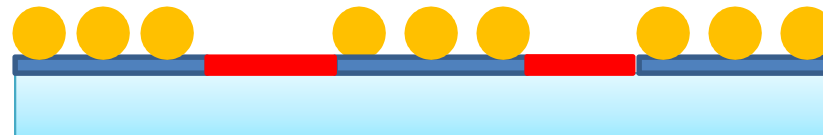
Al deposition



Acetic Anhydride treatment
Al etch with HCL
Au nanosphere deposition.

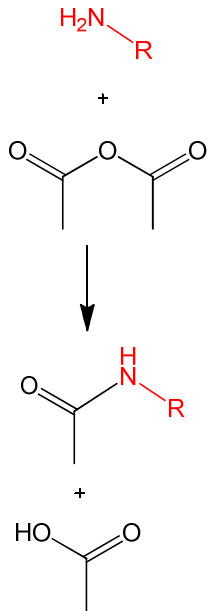
(3)

Nanoparticle
Assembly



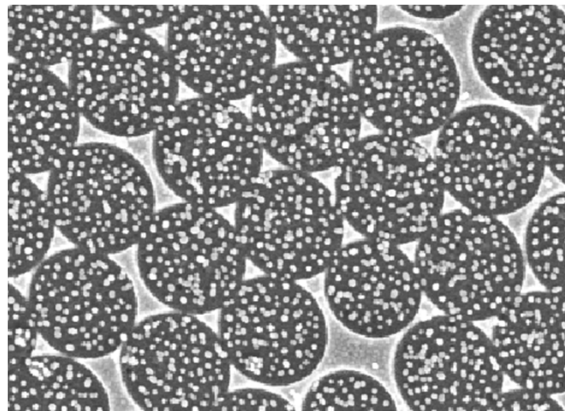
Acetic anhydride passivation

The surface amine can be passivated by acetylation with acetic anhydride

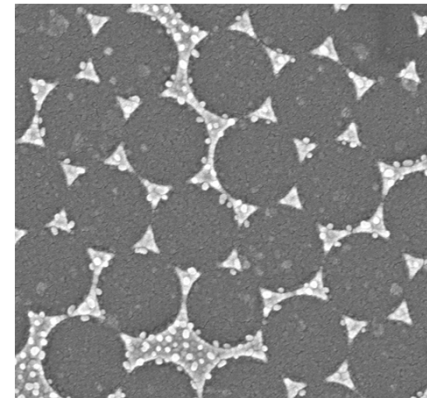


1. Expose to neat acetic anhydride for 20 min.
2. Rinse

Passivation prevents absorptions of additional particles

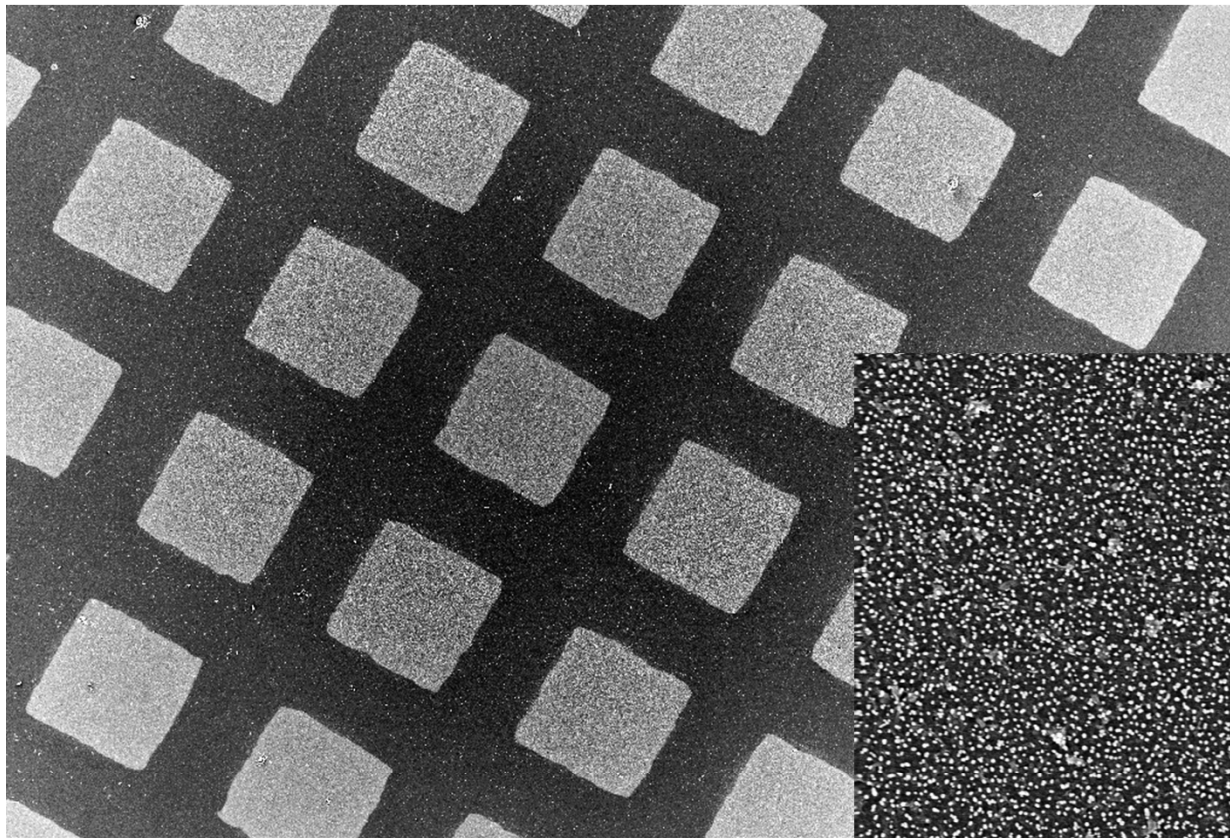


without passivation



with passivation

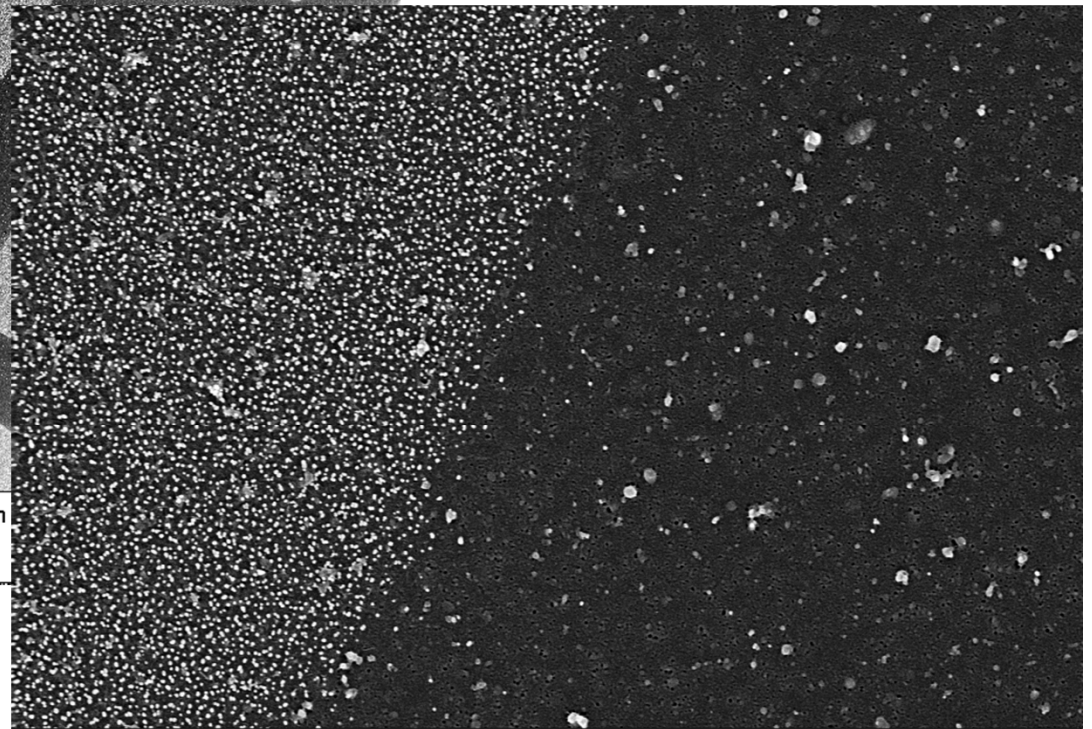
Selective assembly of gold nanoparticles on patterned ISAM film



Acetic Anhydride, Al etched
Nano Spheres

20 μ m
H

WD = 4 mm
Mag = 500 X

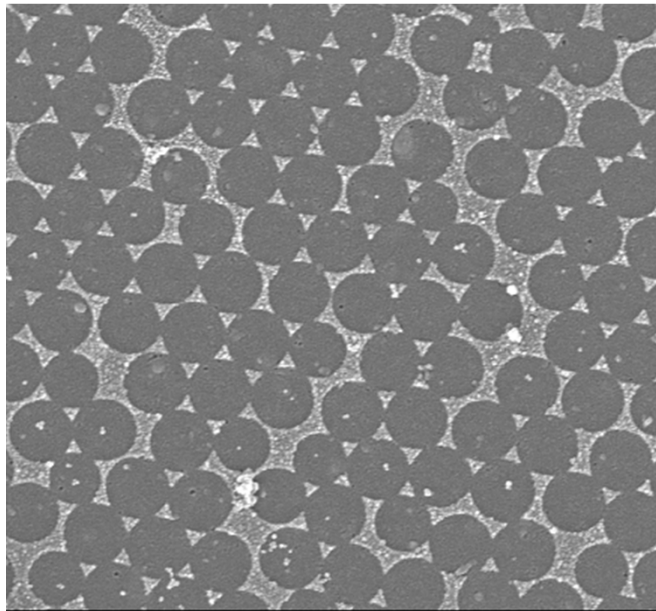


ISAM pH 9.45, Acetic Anhydride, Al
etched Nano Spheres

200nm
H

WD = 4 mm EHT = 3.00 kV Date :21 Aug 2011
Mag = 35.00 K X Photo No. = 4736 Signal A = InLens

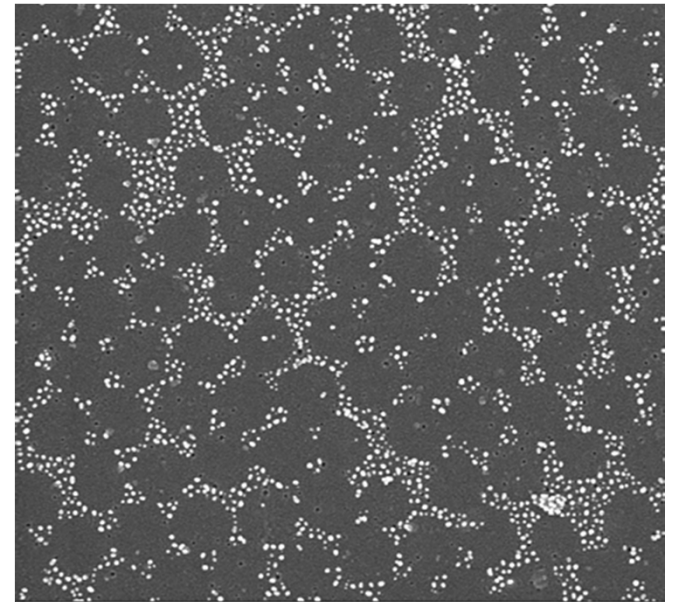
High resolution adhesion modification patterning



1. Adhere Al pattern
2. Passivate with acetic anhydride
3. Etch in 1 mM HCl
4. Deswell at pH 10.25



5. Adsorb Au nanoparticles



Adhesion-patterning “lithography”

Summary

- PAH terminated ISAM films provide amine rich “sticky” surfaces.
- Surface adhesion properties can be patterned by laser ablation or chemical manipulation
- Sub micron resolution can be achieved by both techniques
- Applications in nanodevice fabrication, cell biology and tissue engineering